

Multi-spectral Solar Cells

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Background

- We currently work on the design, fabrication, and manufacture of a wide array of photonic devices including: photonic crystals, silicon lasers, high speed modulators and solar cells.
- We have several active projects in silicon photonics: lasers, routers, modulators, MEMS, micro-fluidics, OPSIS (foundry based), etc.
- We have worked on light trapping in thin-film silicon solar cells in the DARPA Very High Efficiency Solar Cell (VHESC) program.
- We have a strong and ongoing collaboration with the Institute of Energy Conversion (IEC) at the University of Delaware, where we apply photonic engineering device concepts to thin-film solar cells (CIGS).



Our Vision

- To reach the “next level” of solar cell engineering, a holistic approach to design, integration, and manufacturing where materials, devices, and photonic engineering are monolithic.
- Application of photonic engineering device concepts to photovoltaics is non-trivial, it needs a multi-disciplinary approach where groups of various backgrounds work seamlessly together.
- For this to happen, a new paradigm is needed where the emphasis is on synergy and finding ways that different technologies can be mutually beneficial.
- A good example of this is the semiconductor manufacturing industry, where all components are built to work together from the on-set to build > 60% efficient solar cells, under very high concentration 10,000X.

Nano-Fabrication Facility



EQUIPMENT:

UV, DUV, AND EB EAM LITHOGRAPY

ICP ETCHING WITH FL AND CL GASES

PECVD, MOCVD, MBE

EBEAM EVAPORATION

CHIP PACKAGING

FLIP-CHIP BONDING

DIFFUSION FURNACES

RF TESTING AND INTEGRATION

Deposition

SAMCO PD220
Plasma-enhanced
Chemical Vapor Deposition

BOC Edwards 306
Electron-beam
Evaporator

SVT Molecular Beam
Epitaxy System

Lithography

Raith 50 Electron-beam Lithography system

Spectra-Physics DCR-4 Nd:YAG laser

50- μm grayscale
YouDee:
e-beam lithography

Micro-ring resonator:
E-beam lithography +
ICP etching

Photonics crystal waveguide:
Combination E-beam/
Laser interference
lithography, ICP etching

Si MEMS actuator:
UV photolithography +
ICP etch

Grayscale optical devices:
E-beam lithography +
ICP etching

3D polymer photonic crystal:
Laser interference lithography

3D polymer photonic crystal:
multilayer UV photolithography

13-nm electrode gap:
electron-beam lithography

Metal nanodot array:
E-beam lithography +
evaporation

AlGaAs detectors:
Epitaxial structure +
ICP etching

3D Silicon photonic crystal:
deep anisotropic etching

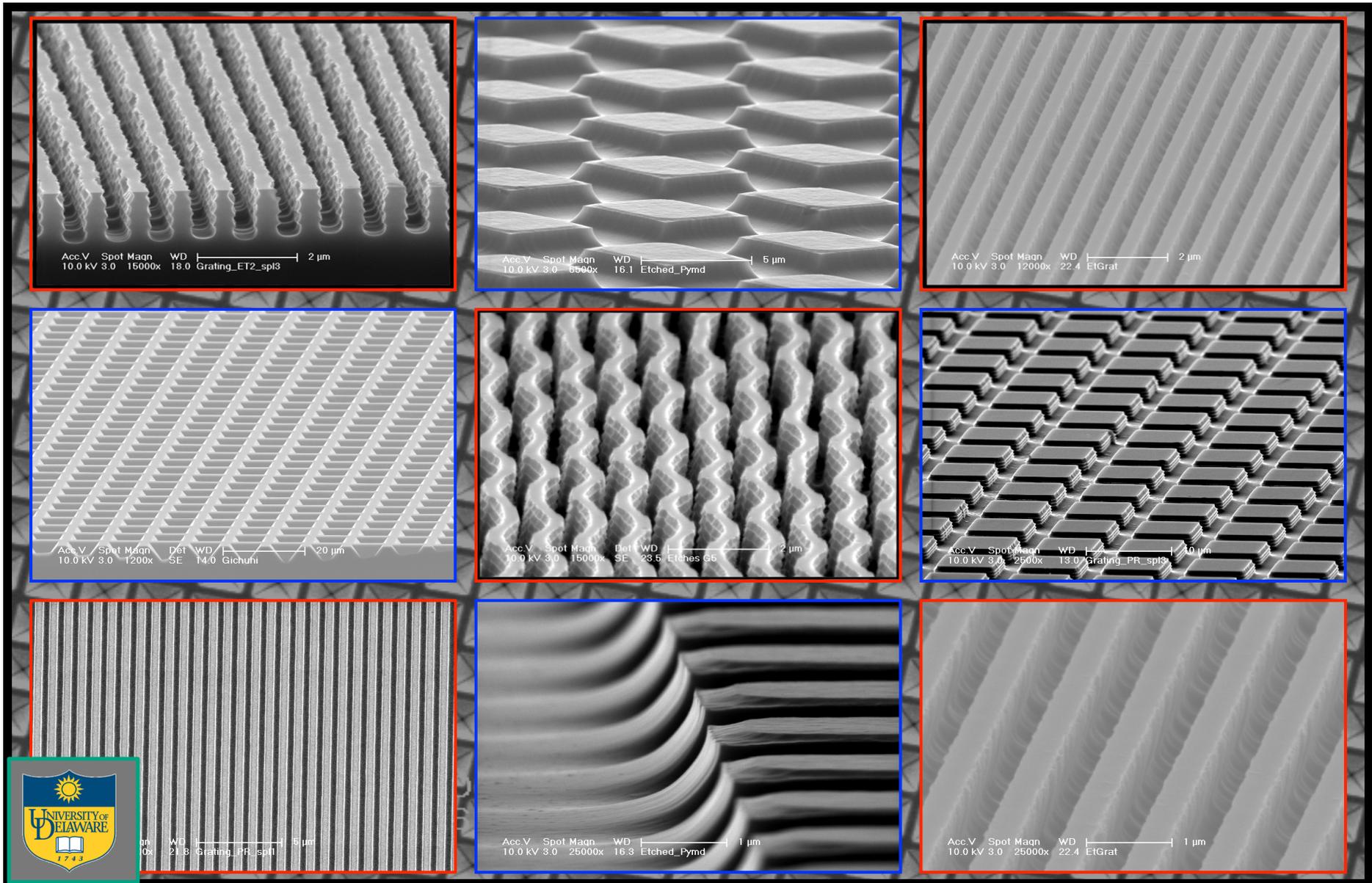
Etching

SAMCO RIE-200iP
Inductively Coupled Plasma
Reactive-ion Etching System:
Chlorine Chemistry for III-V materials

SAMCO RIE-200iP
Inductively Coupled Plasma
Reactive-ion Etching System:
Fluorine Chemistry for Silicon

ABM, Inc. Deep-UV Contact
Mask Aligner

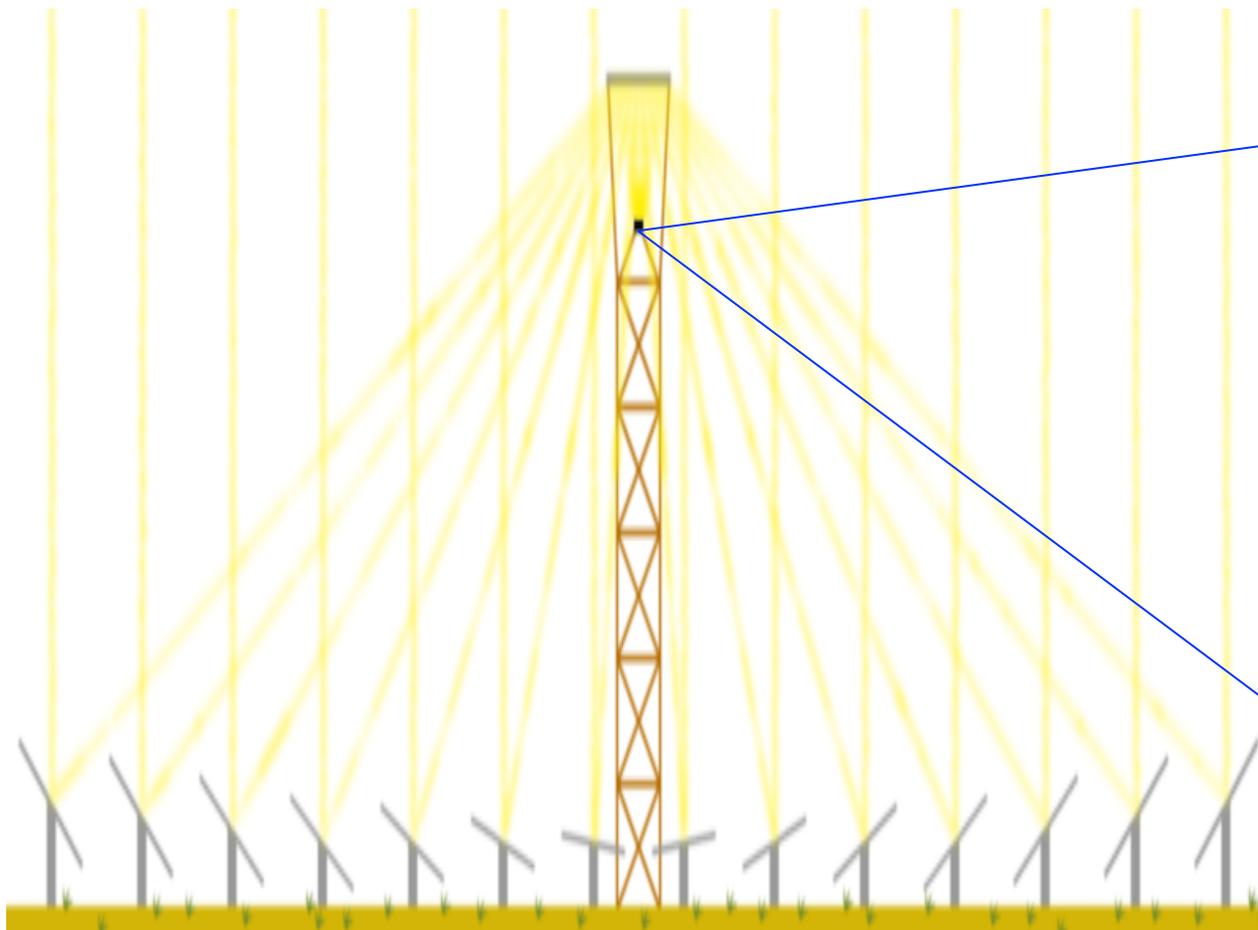
Fabrication of Micro and Nano Structures



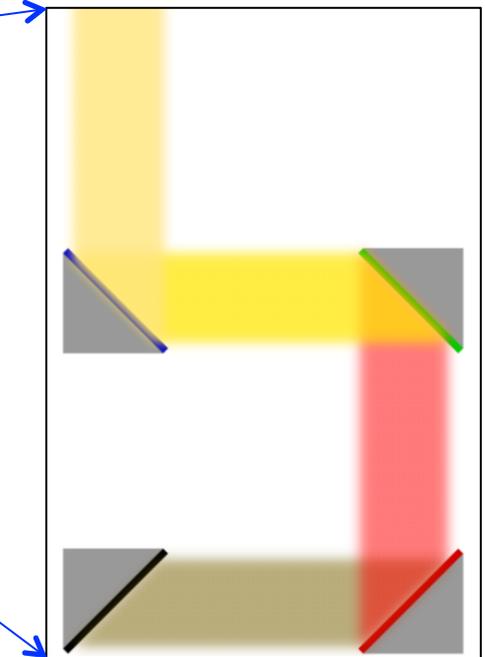
Solar Tower and Light Spectrum Splitter



Concentrating Solar Tower

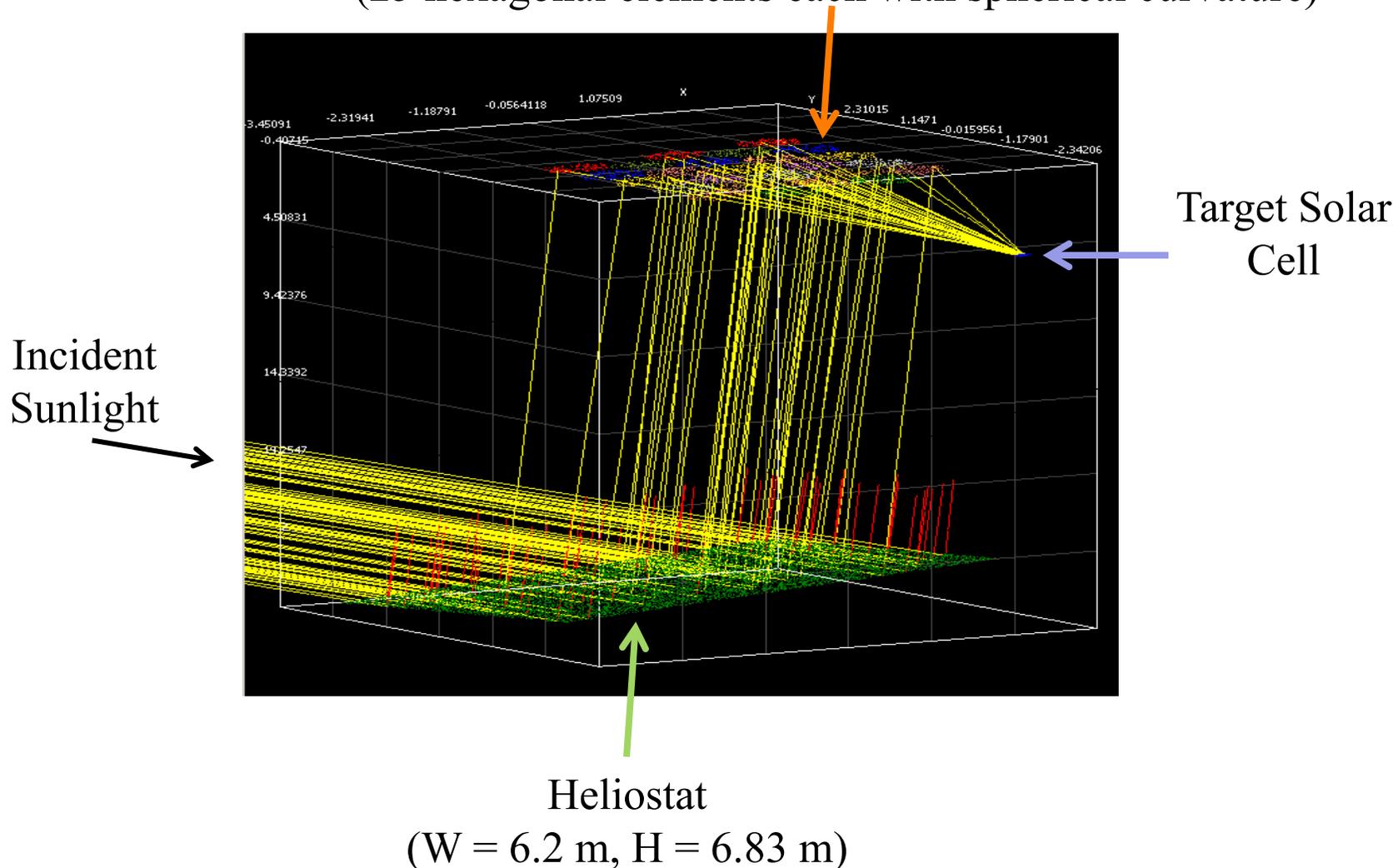


Multi-spectral Solar Cells



Intersection Plot for Concentrator Field

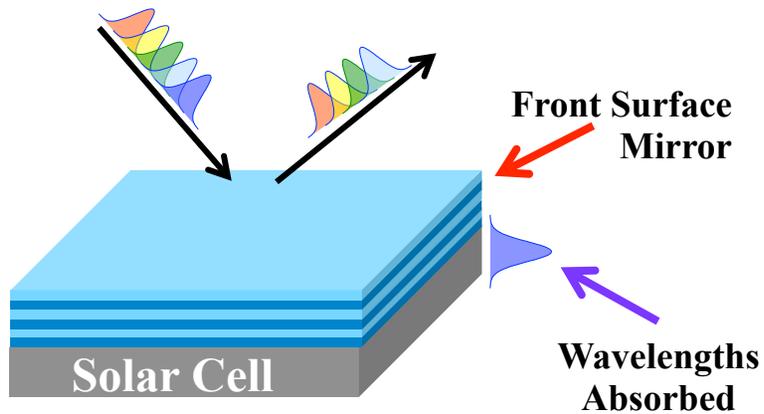
Primary Concentrator Mirror
(25 hexagonal elements each with spherical curvature)



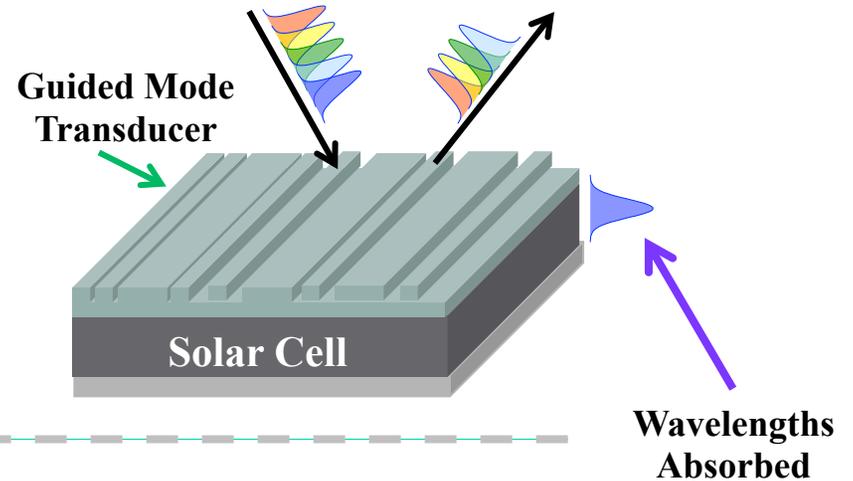
Multi-spectral Solar Cells



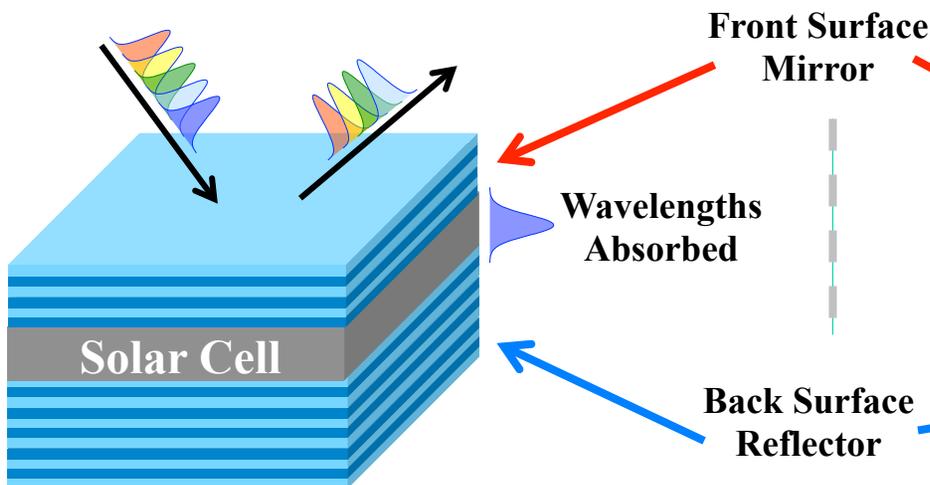
Solar Cell with Front Surface Reflector



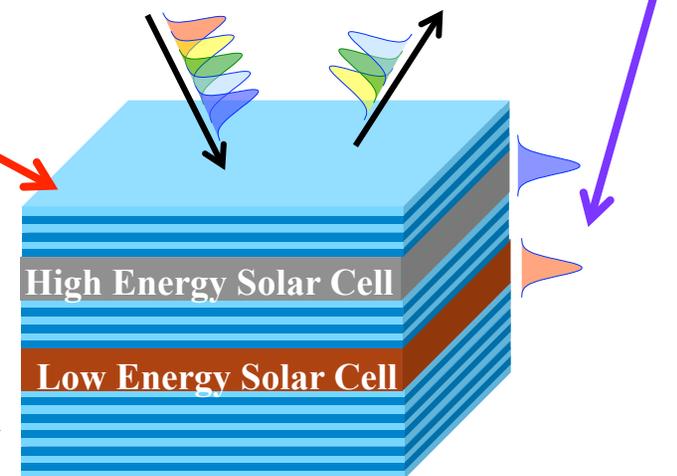
Solar Cell with Guided Mode Transducer



Solar Cell with Front and Back Surface Reflector



Multiple Stacked Solar Cells

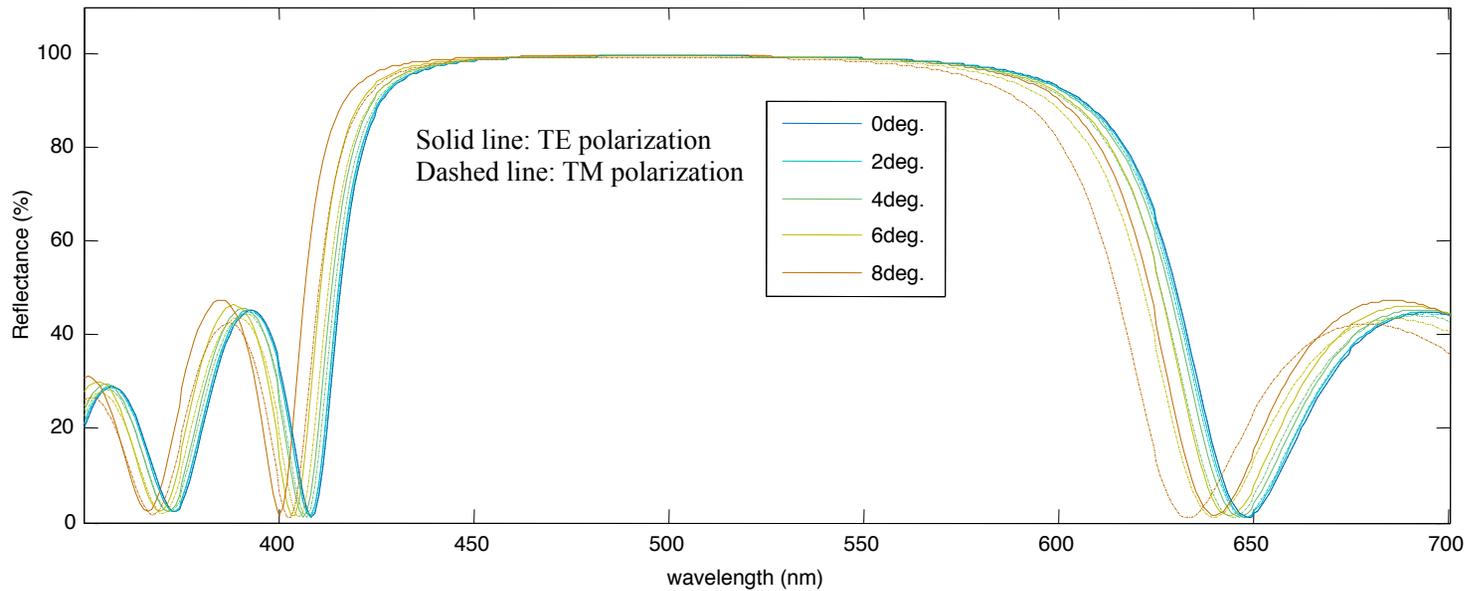
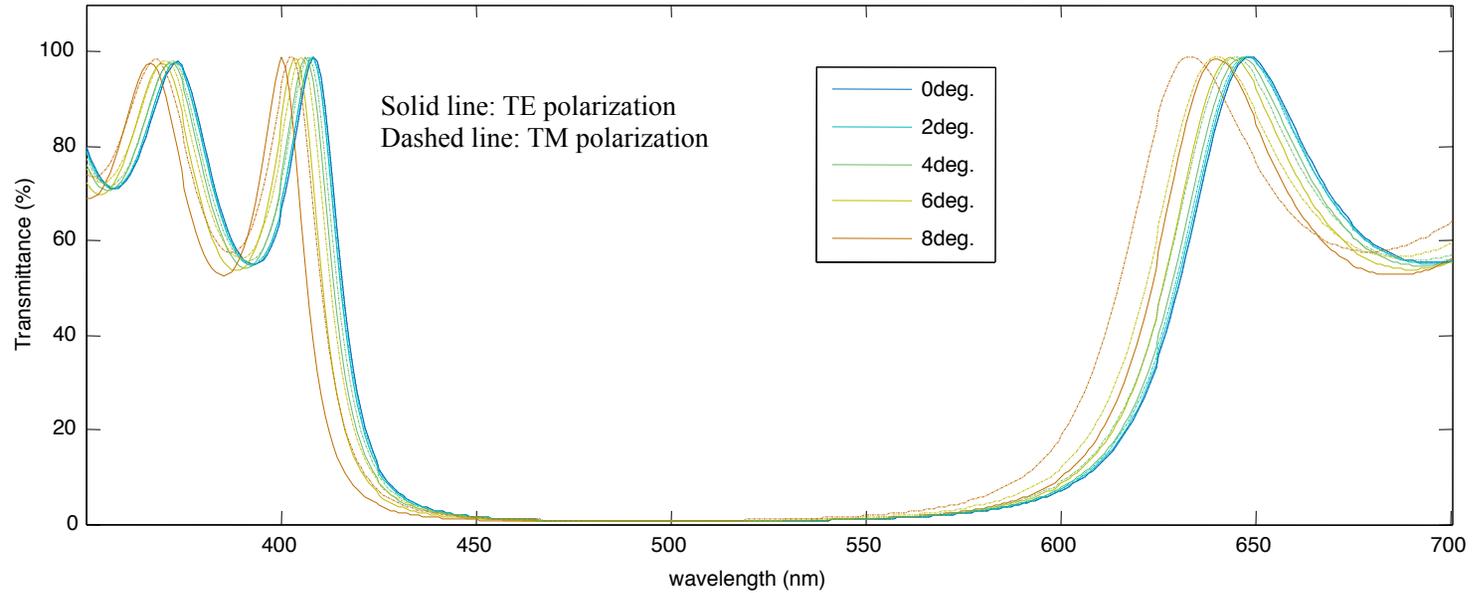
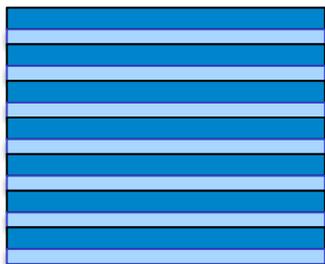
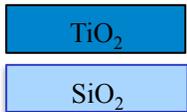


Broadband Photonic Bandgap Reflectors



1D photonic
bandgap materials

Center wavelength: 500nm
Bandwidth: 420 - 600nm
7 periods
Index contrast: $\sim 2.5/1.46$

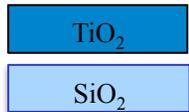


Broadband Photonic Bandgap Reflectors



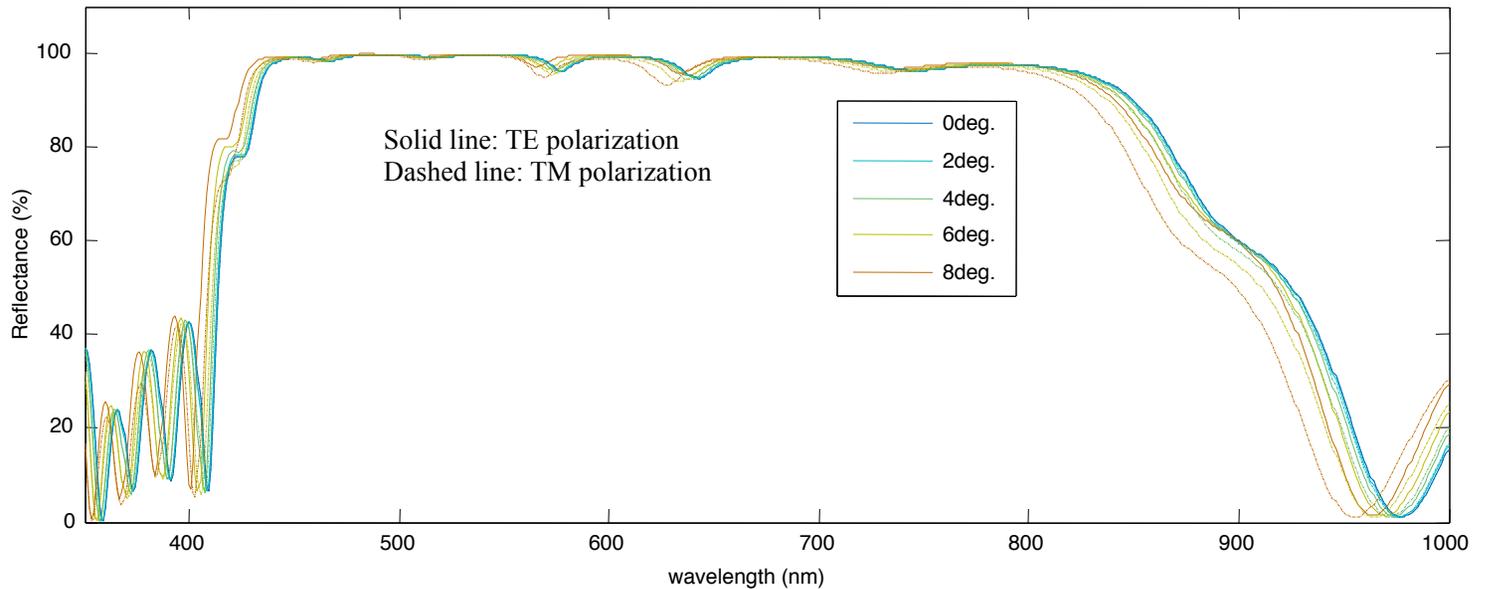
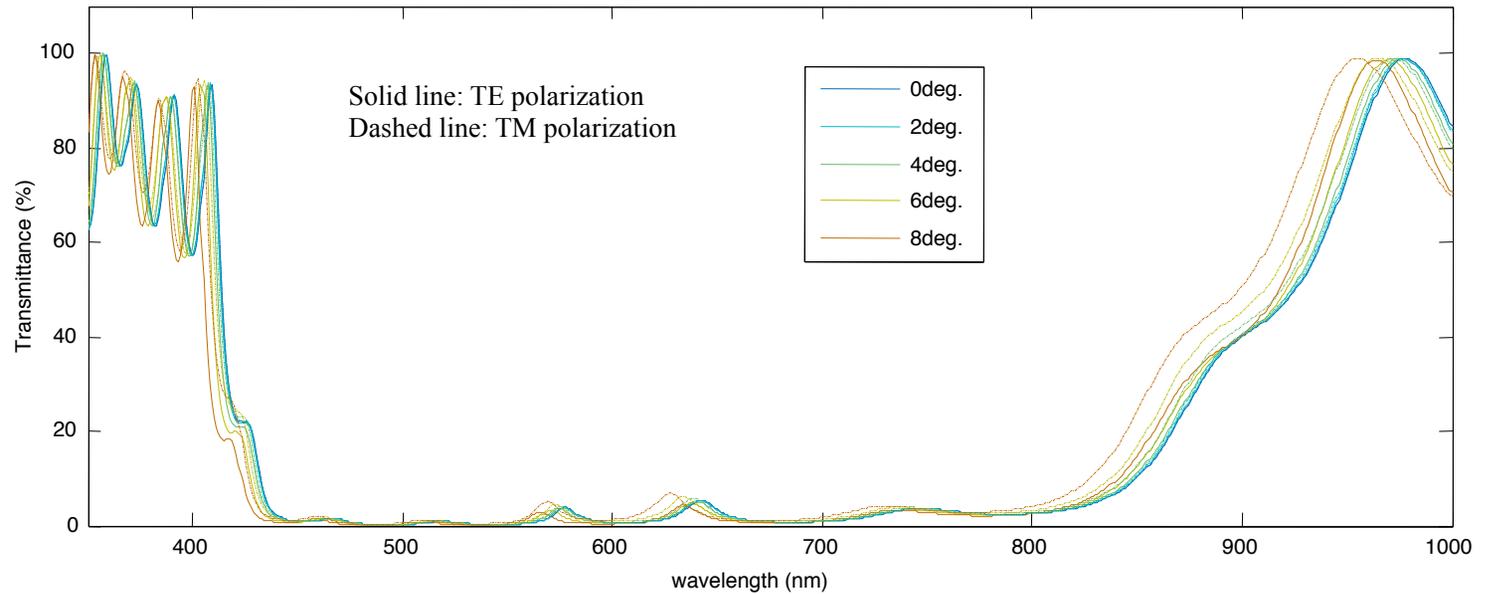
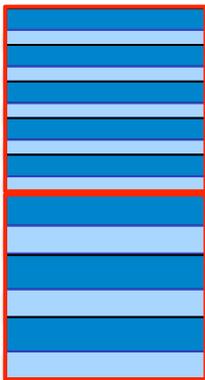
1D photonic
bandgap materials

Center wavelength: 500nm
Bandwidth: 420:600nm
6/6 periods
Index contrast: $\sim 2.5/1.46$



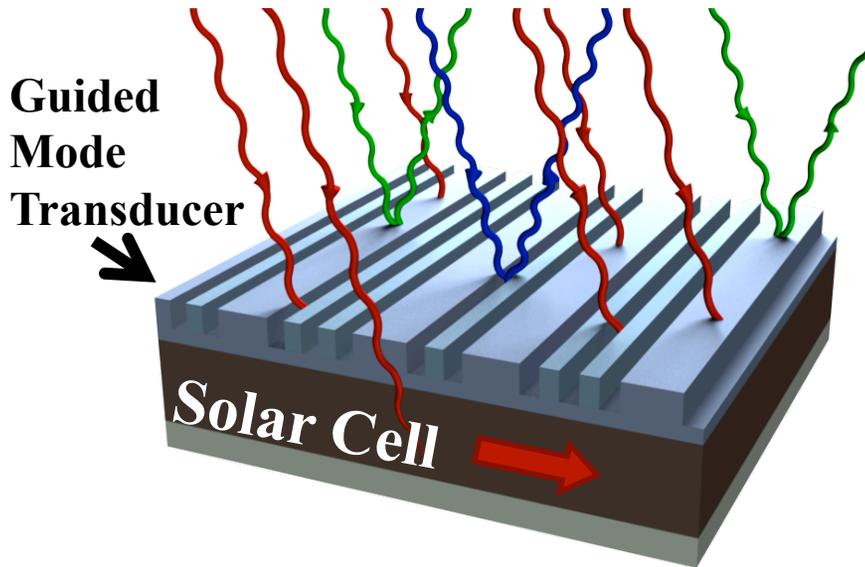
Bandgap #1:
420 – 600 nm

Bandgap #2:
600 – 900 nm

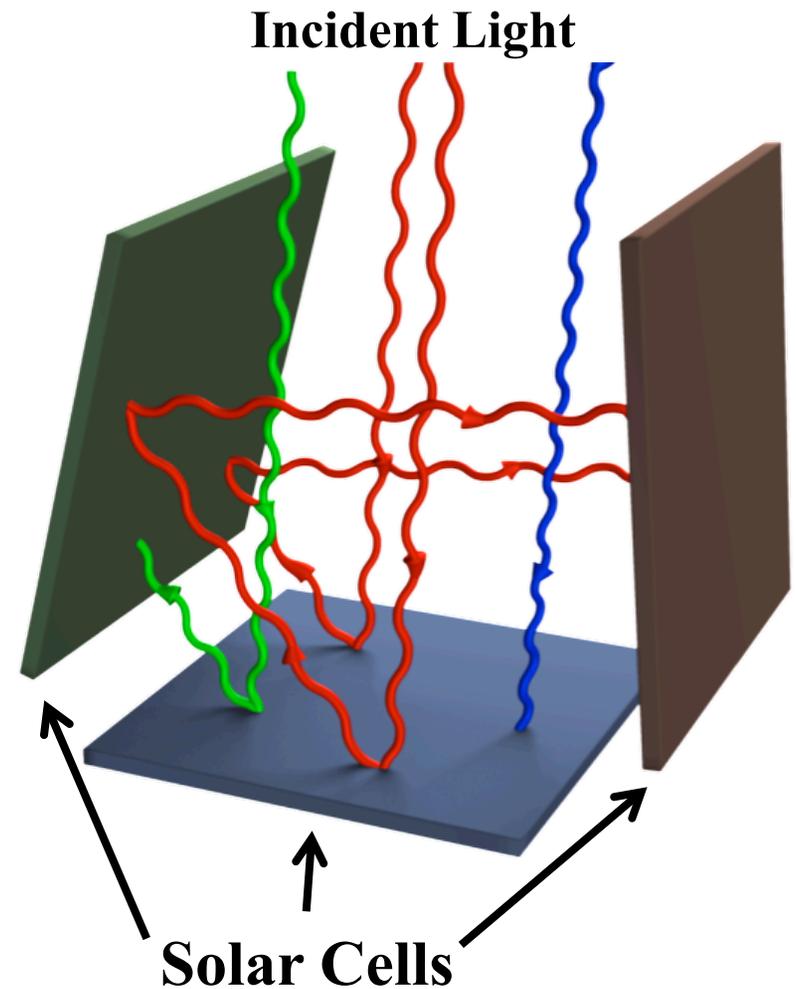


Mode Transducer Enhanced Solar Cells

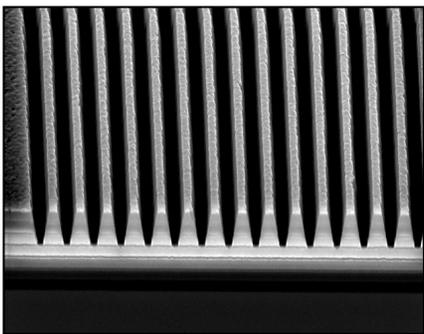
Solar Cell With Guided Mode Transducer



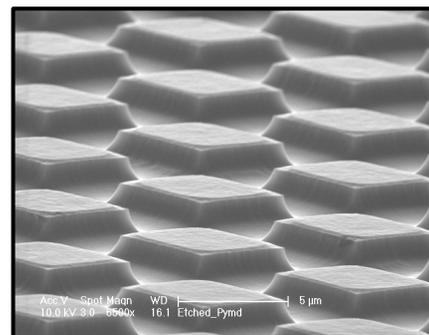
Multiple Guided Mode Transducer Enhanced Solar Cells



Fabrication of Guided Mode Transducer

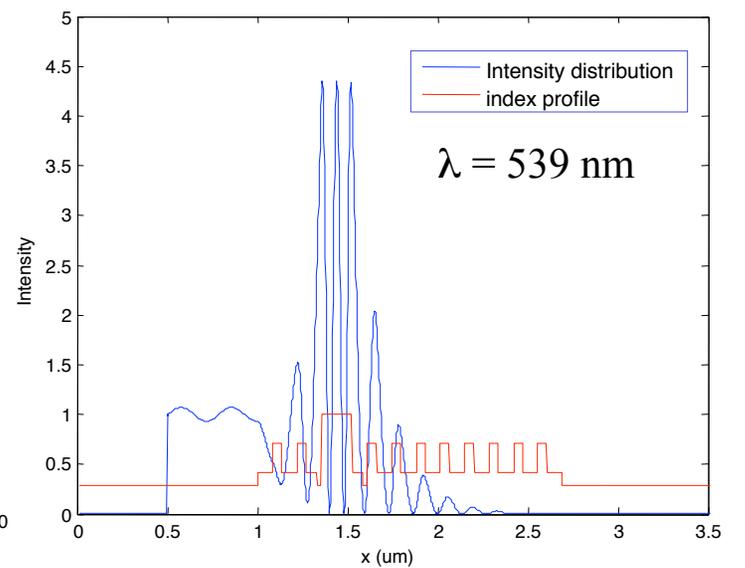
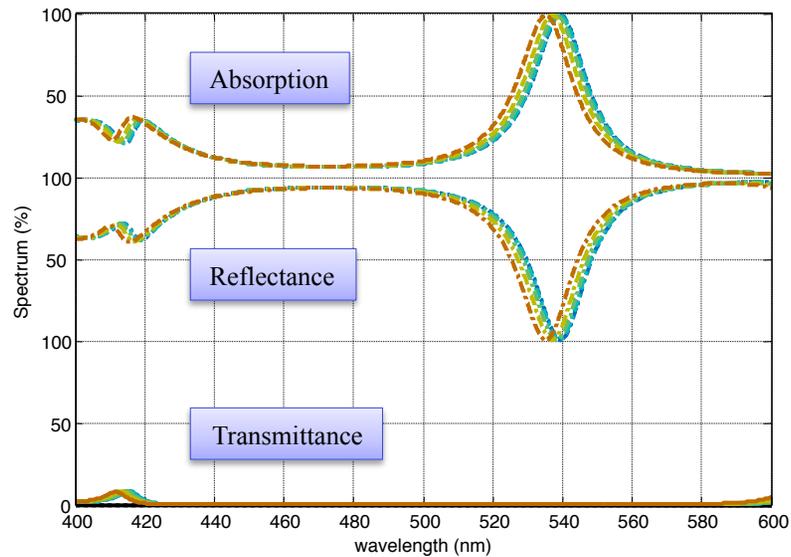
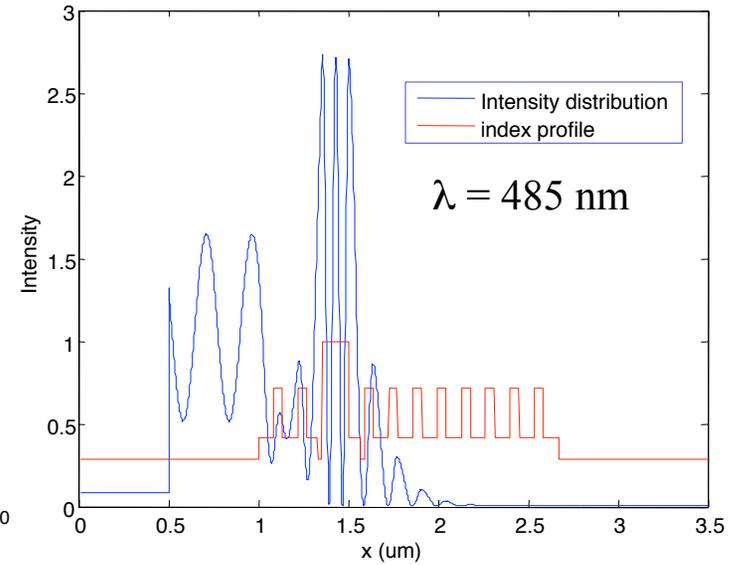
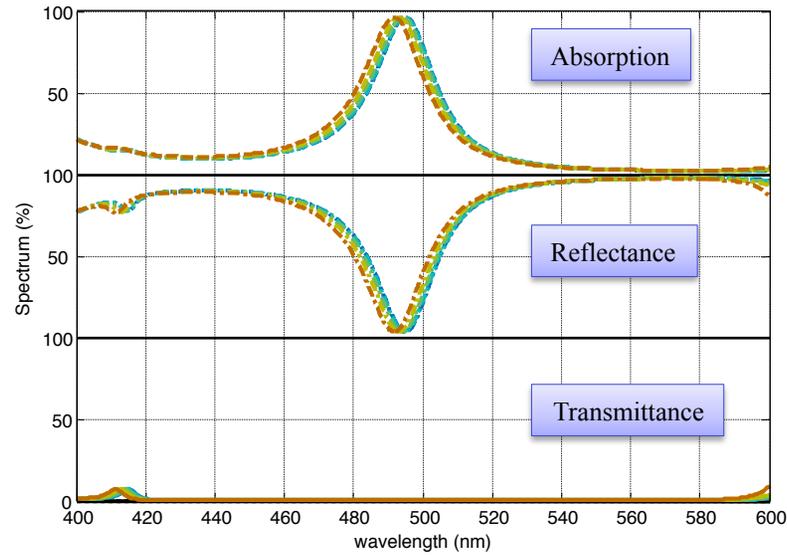
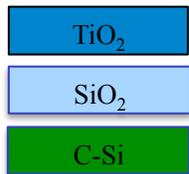
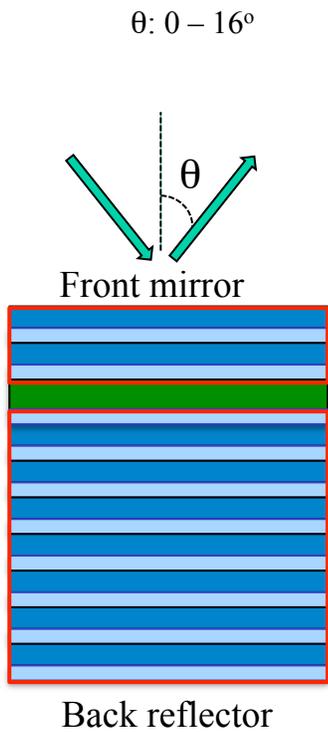


Nano-scale Gratings



Micro-scale Features

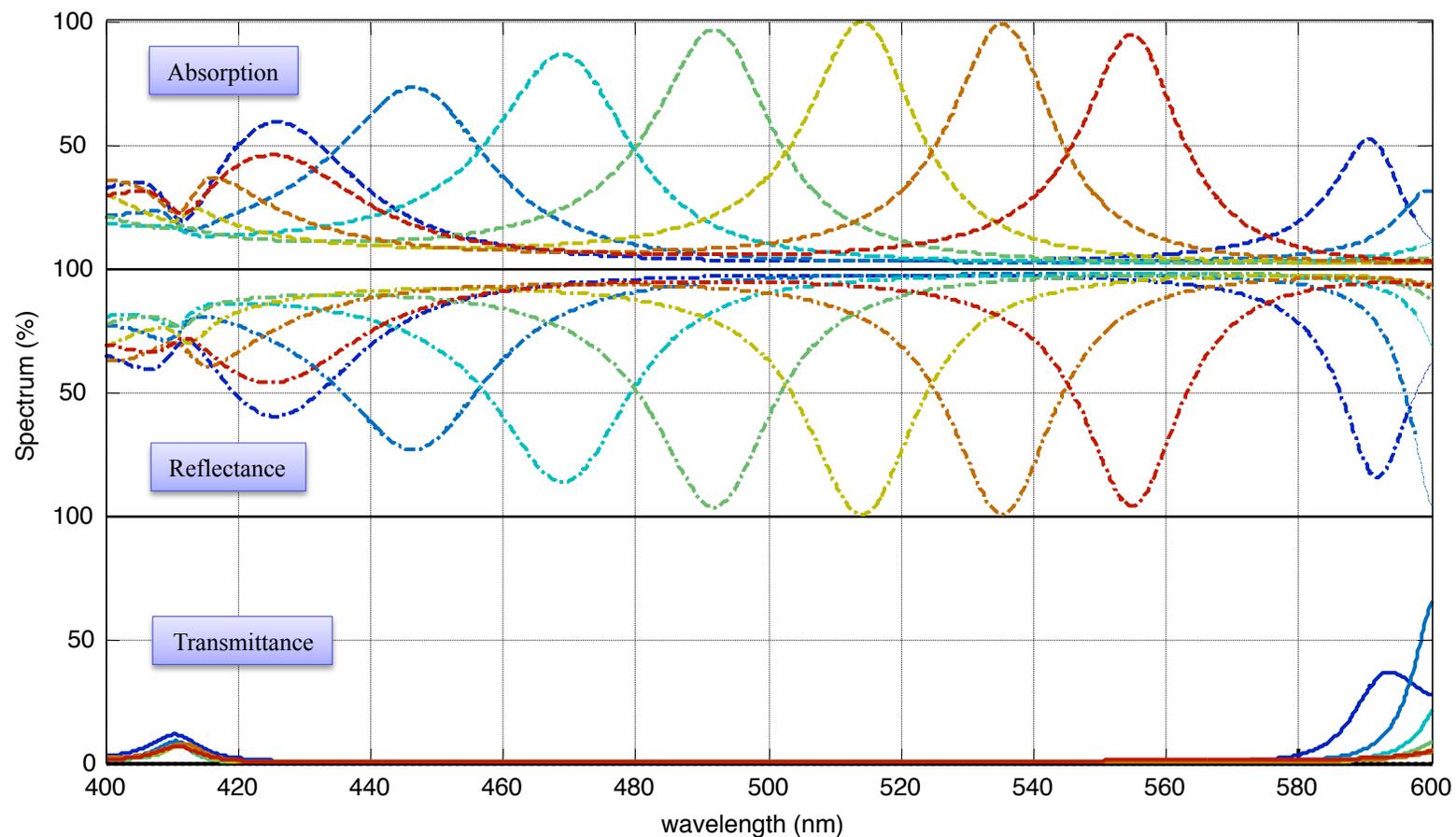
Multi-spectral Solar Cells



Multi-spectral Solar Cells

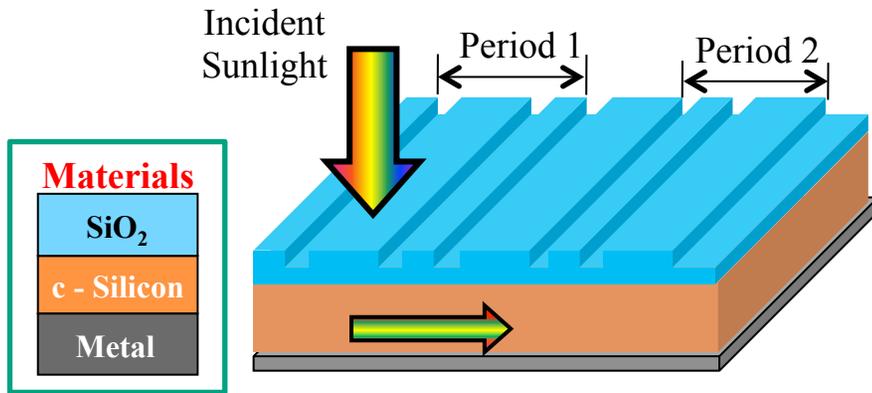


- Simply change the active layer (solar cell) thickness, we can tune the peak absorption spectrum
- Further optimization can be used to improve the absorption at the design wavelength

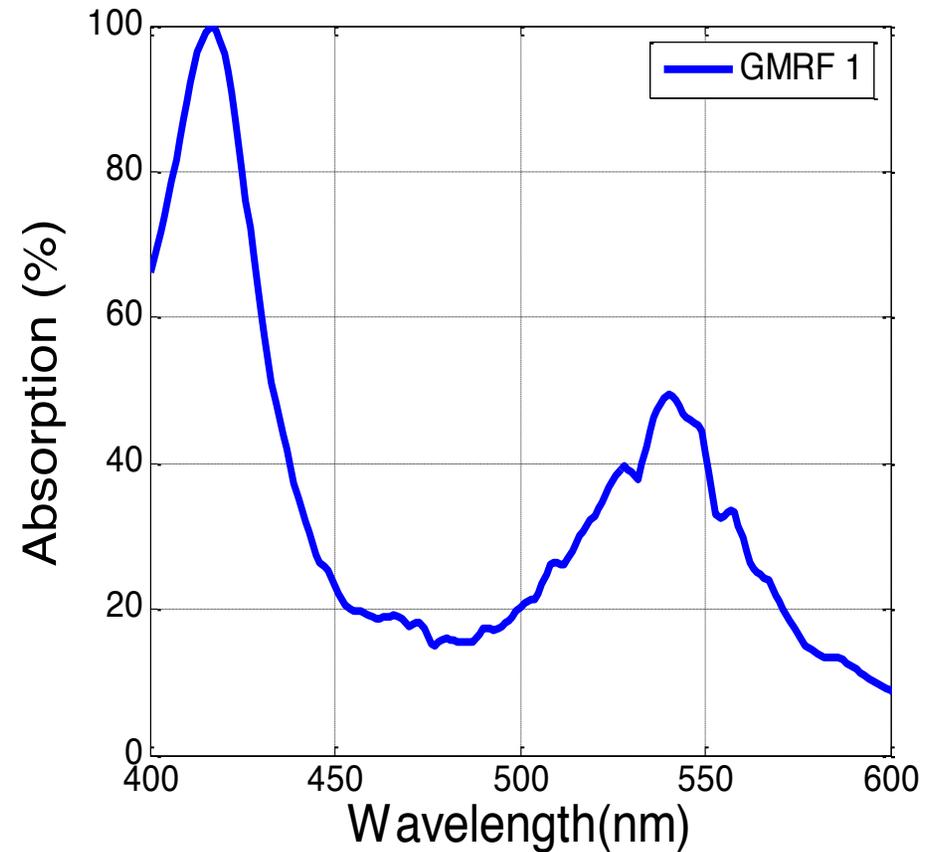


GMRF Enhanced Solar Cells

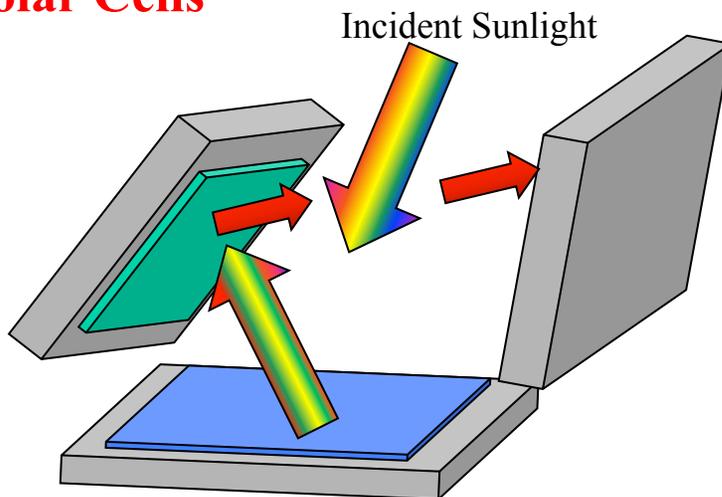
Solar Cell With GMRF



Absorption of Single GMRF Enhanced Silicon Solar Cell



Multiple GMRF Enhanced Solar Cells

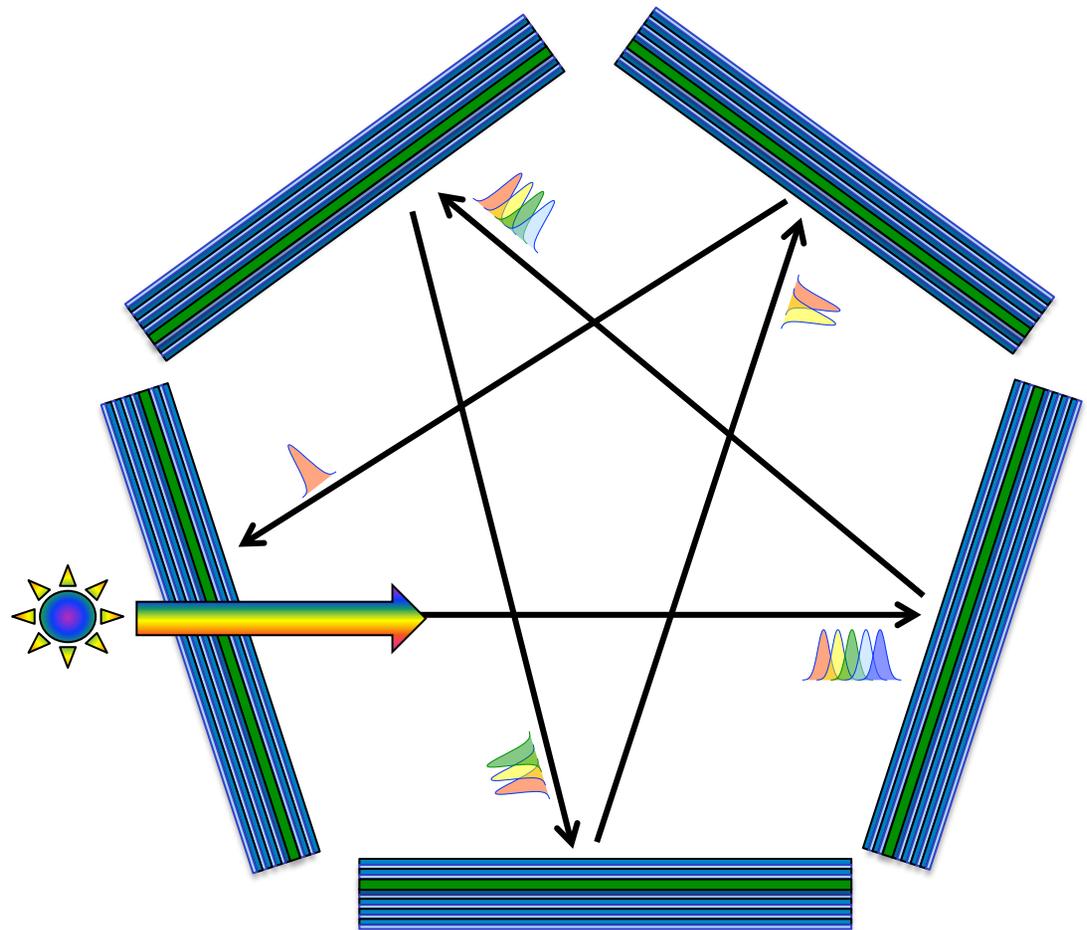


(all less than 1 micron thick)

Multi-spectral Solar Cells

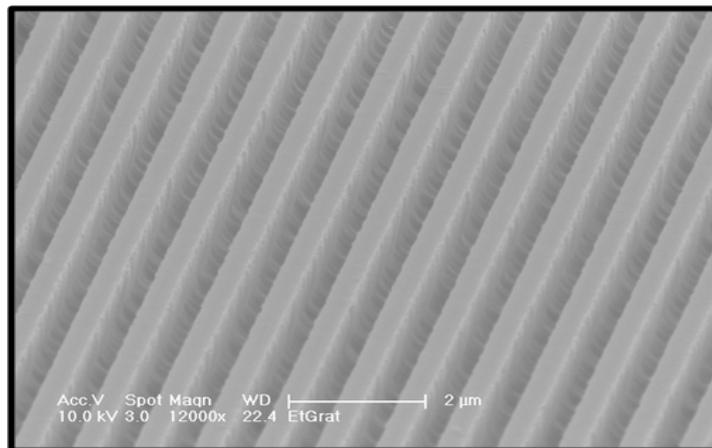
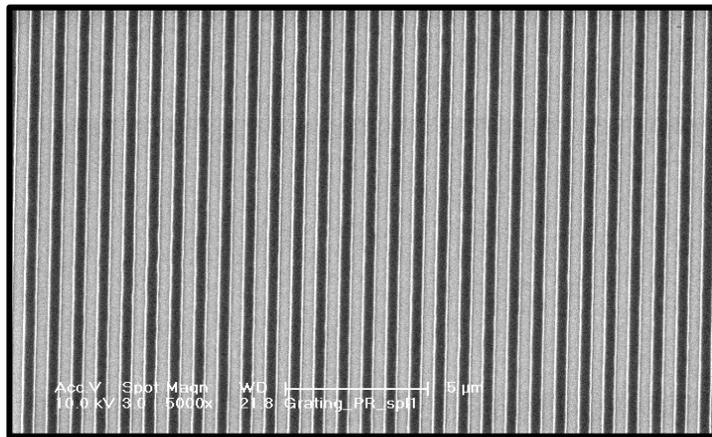


- One-dimensional micro-cavity is designed to capture a narrow band of the solar spectrum.
- Each cavity consists of an ultra wide band back reflector, a front reflector, and an active solar cell material.
- Strong resonances in the active solar cell materials allow the captured photons to have much longer life times, or increased optical path lengths, thereby enabling efficient light trapping.
- Multiple solar cells are arranged along the contour of a cylindrical surface. After the desired wavelength is absorbed in a particular cell, the remainder of the solar spectrum will propagate along the designed optical path and hence, will get absorbed in subsequent cells on the cylindrical surface.

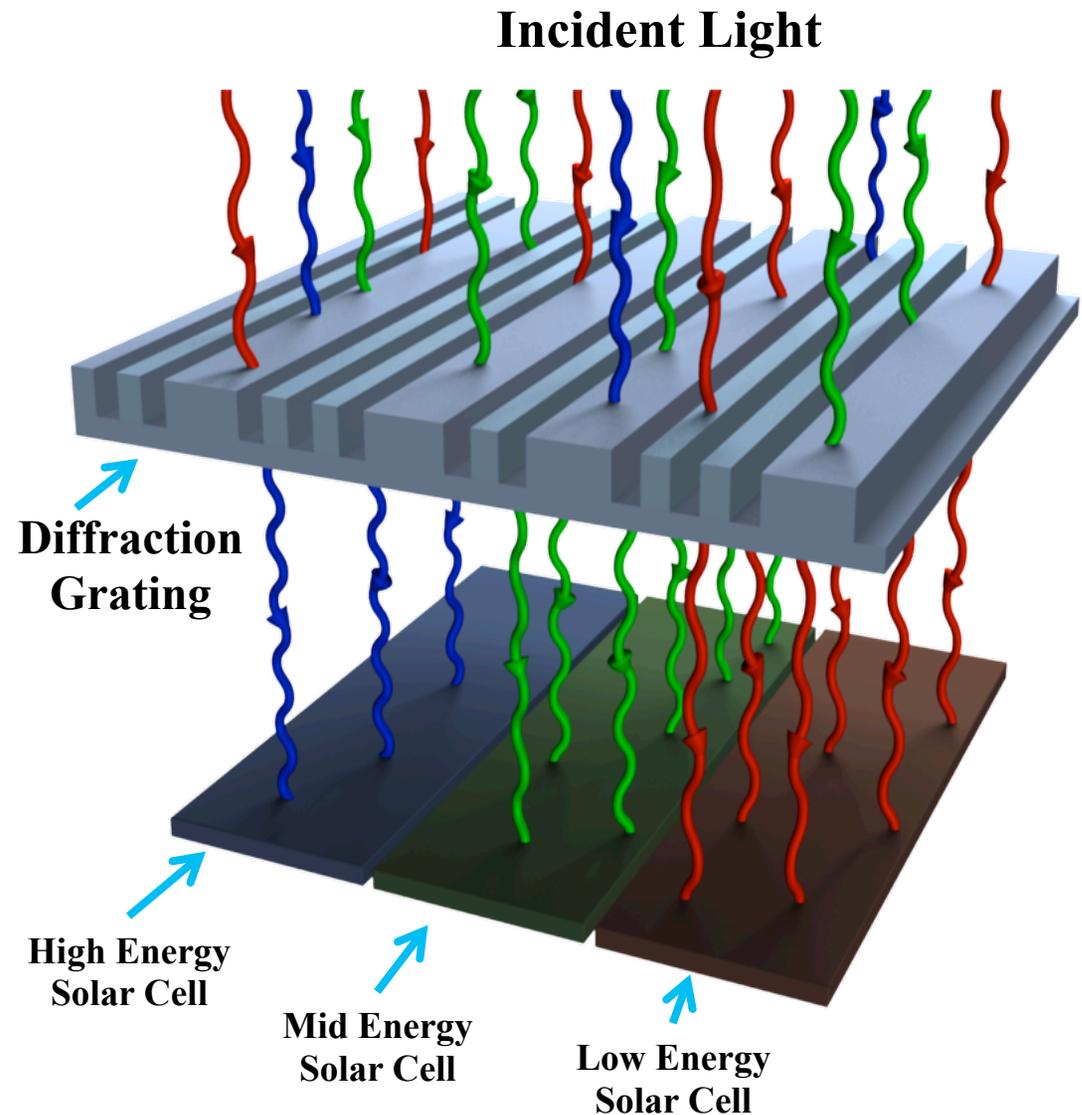


Spectrum Splitting using Gratings

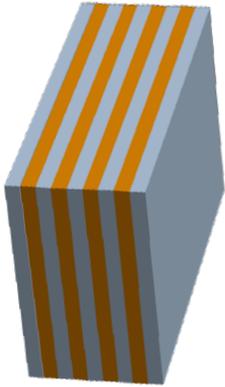
Diffraction Gratings for Light Splitting



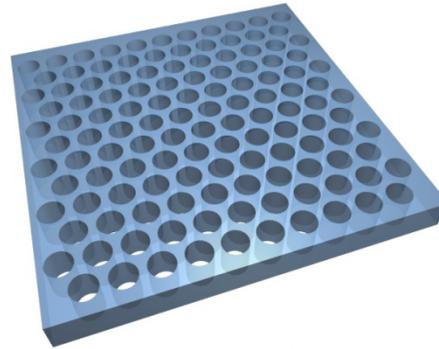
Spectrum Splitting Structures



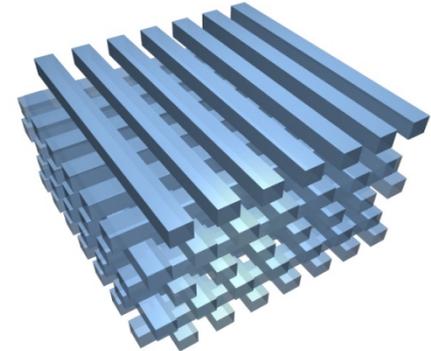
Photonic Crystals



1D Photonic Crystal



2D Photonic Crystal



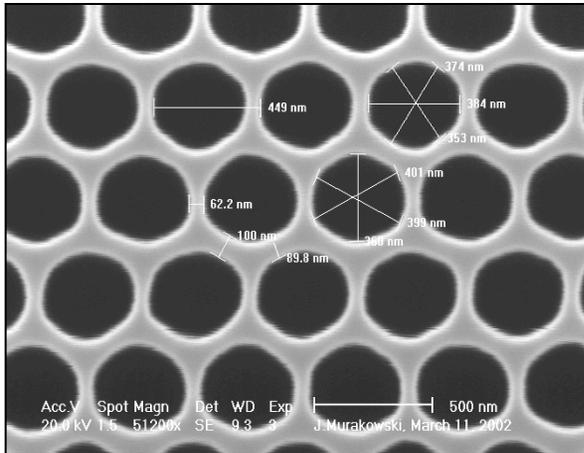
3D Photonic Crystal

- A PhC is a periodic arrangement of dielectric or metallic materials with a lattice constant comparable to the wavelength of an electromagnetic wave.
- They were first proposed in 1972 by Vladimir P. Bykov and later in 1987 by Eli Yablonovitch, as a means to control spontaneous emission.
- When a coherent source interacts with a periodic structure, interesting effects occur.
- One of the more interesting effect is the grouping of allowed states into discrete bands, which are separated by ‘band gaps,’ wherein no states are allowed.

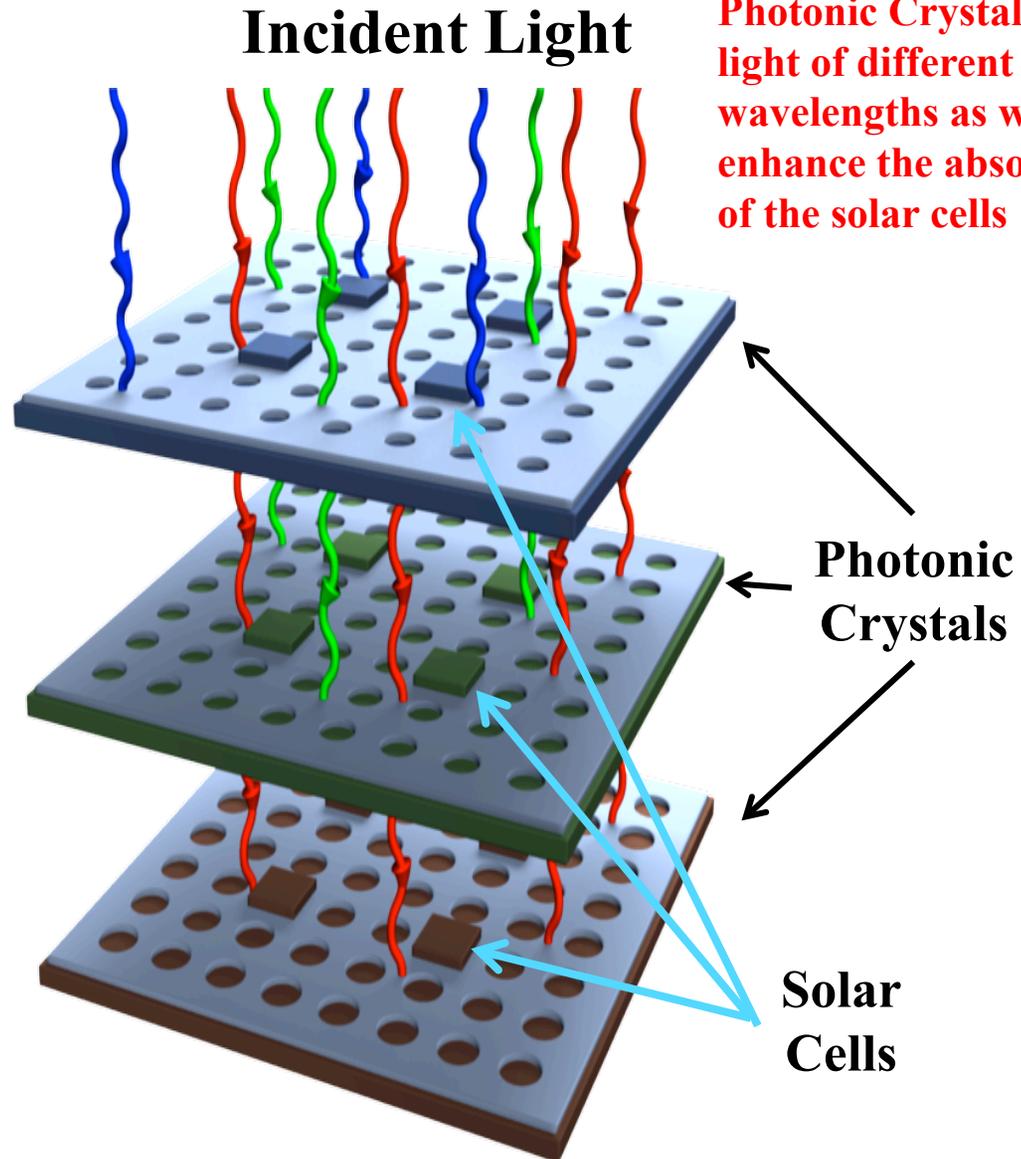
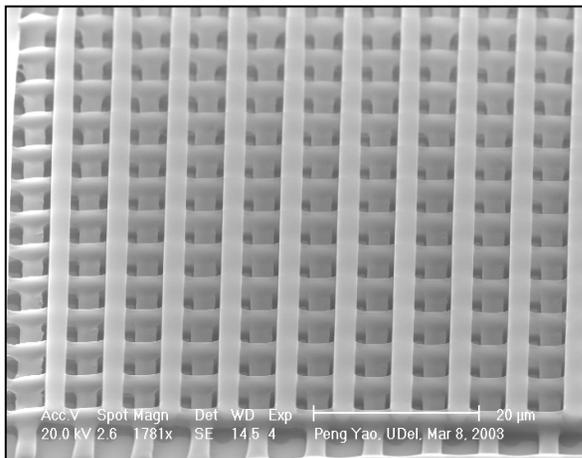
Spectrum Splitting using Photonic Crystals



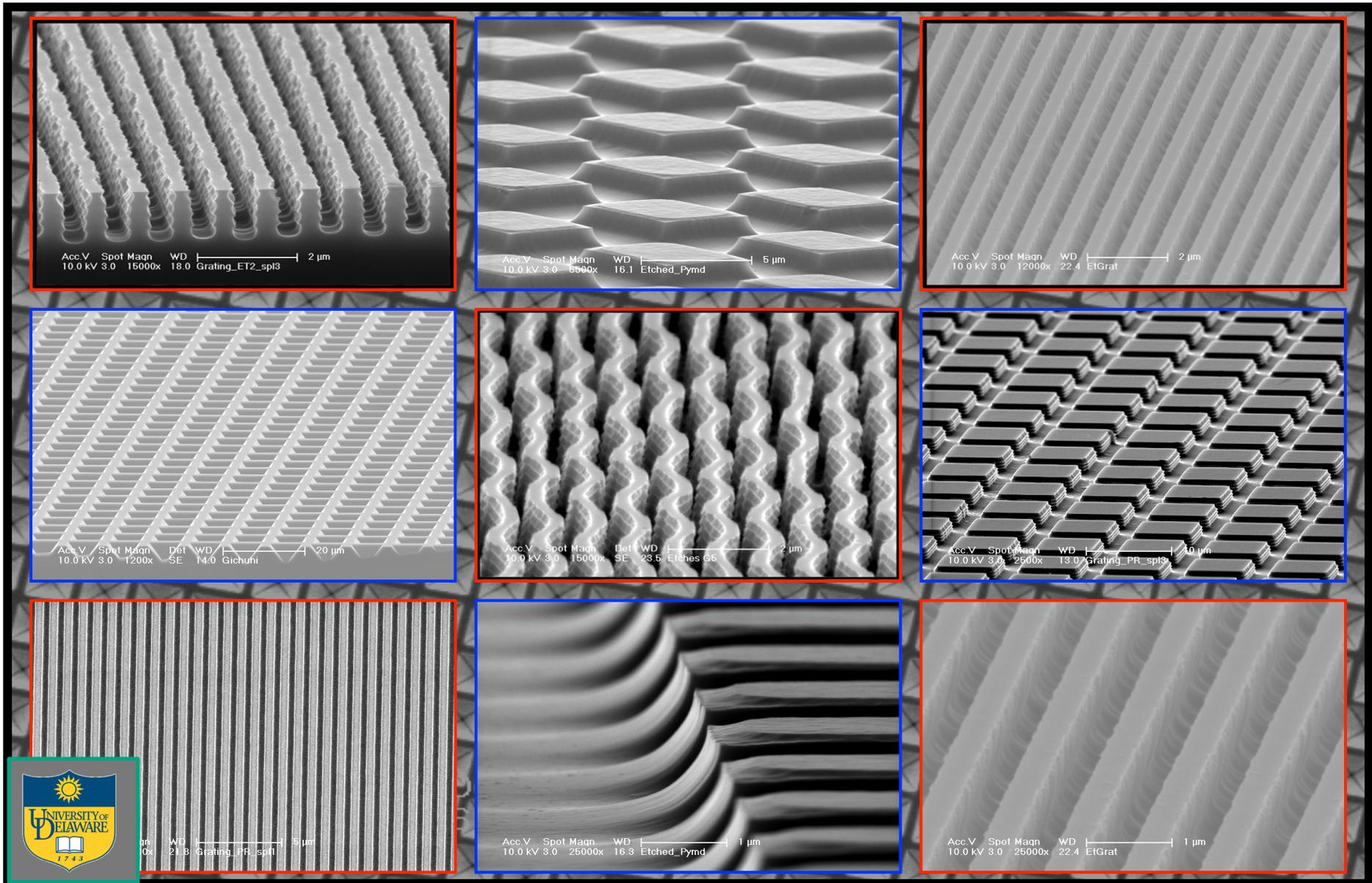
2D PhC



3D PhC



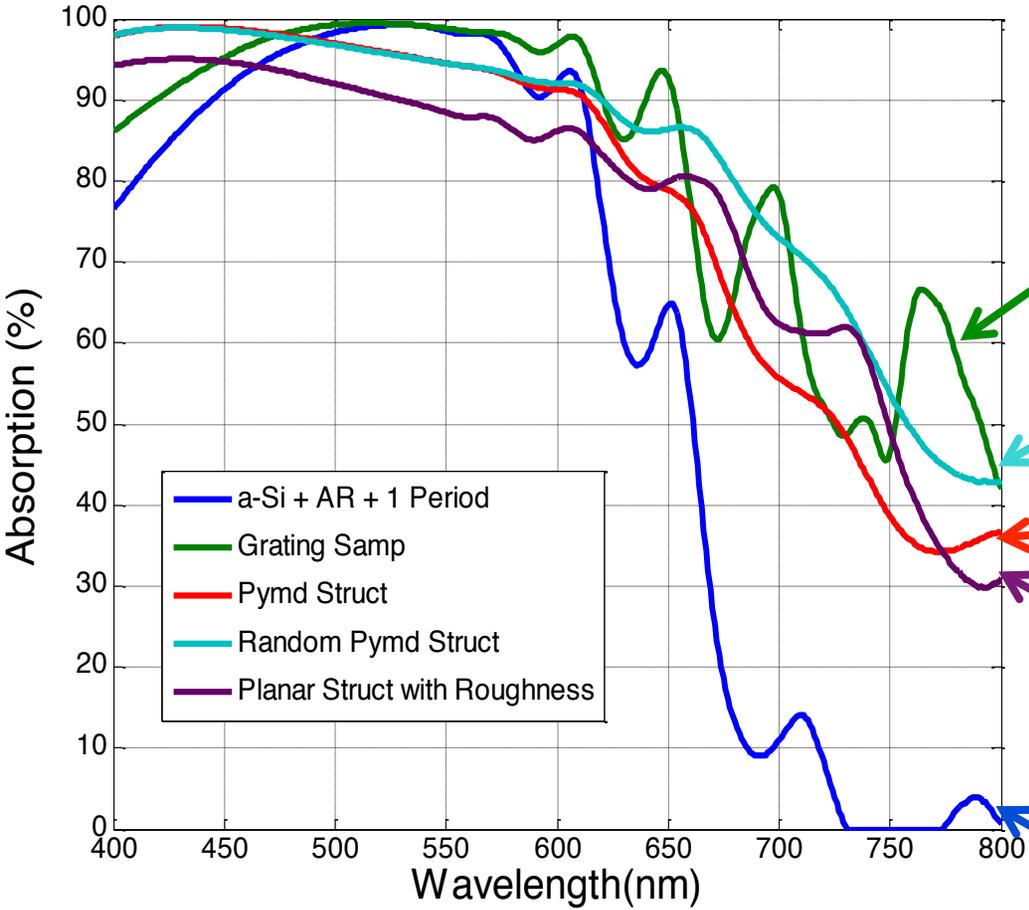
Fabrication of Micro and Nano Structures



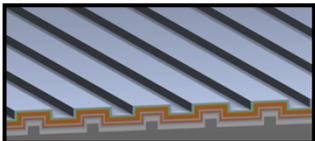
a-Si Solar Cells on Textured Substrates



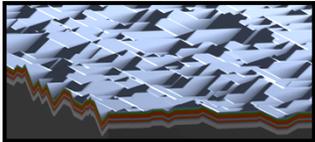
Light Trapping (Measured Absorption)



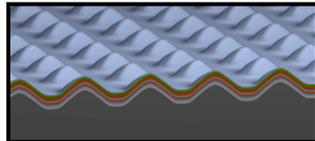
Structures: Absorption (%)



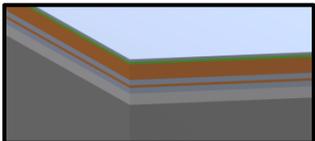
Grating Structure: 83%



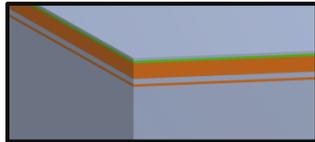
Random Pyramid: 83%



Pyramid Structure: 78%



Planar Structure: 79%



a-Si with AR: 60%

